Block copolymer route towards poly(vinylidene fluoride)/poly(methacrylic acid)/nickel nanocomposites

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Electronic Supplementary Information



Figure S1. DSC curves of (a) chlorine-terminated PVDF, (b) P*t*BMA-*b*-PVDF-*b*-P*t*BMA triblock copolymer and (c) PMAA-*b*-PVDF-*b*-PMAA after hydrolysis.



Figure S2. (a) Kinetic plot and (b) linear dependence of molecular weight on the monomer conversion.



Figure S3. SAXS patterns of P*t*BMA-*b*-PVDF-*b*-P*t*BMA (a) in the melt state at 180 °C and (b) at room temperature.



Figure S4. SEM image of a cross section of the polymer film after hydrolysis of the *tert*-butyl moieties of P*t*BMA.



Figure S5. Complete WAXS pattern of PVDF/PMAA/Ni nanocomposite.